

In the Claims:

Claim 1. (Currently Amended): A phase shift mask, comprising: a transparent substrate having a trench in a trench-type guard ring pattern for shifting the phase of light transmitted therethrough by 180°; and a half-tone phase shift pattern disposed on the transparent substrate and surrounded by the guard ring pattern.

Claim 2. (Original) The phase shift mask according to claim 1, wherein the transparencies of the transparent substrate and the guard ring pattern are 100%, respectively.

Claim 3. (Currently Amended) The phase shift mask according to claim 1, wherein the transparency of the half-tone phase shift pattern ranges from 0 to 25%, and the half-tone phase shift pattern shifts the phase of light transmitted therethrough ~~theretrough~~ by 0° or 180°.